



PATENT
Attorney Docket No. 203924

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Kodama et al.

Art Unit: 1711

Application No. 09/502,834

Examiner: D. Truong

Filed: February 11, 2000

For: POLYBENZAZOLE ARTICLE
AND PRODUCTION METHOD
THEREOF

**PENDING CLAIMS AFTER AMENDMENTS
MADE IN RESPONSE TO OFFICE ACTION DATED JULY 10, 2001**

1. A polybenzazole article superior in light resistance, which comprises a polybenzazole and a light-resisting agent that allows for a regular reflectance of the article of not more than 30% in not less than 30% of the wavelength region of from 450 nm to 700 nm, wherein the light-resisting agent comprises an aromatic amine or phenol with the proviso that the light-resisting agent does not comprise a dye.

2. The polybenzazole article of claim 1, wherein the light-resisting agent allows for a regular reflectance of the article of not more than 20% in not less than 10% of the wavelength region of from 450 nm to 700 nm.

3. The polybenzazole article of claim 1, which has a strength of not less than 35 g/d.

6. The polybenzazole article of claim 1, wherein the light-resisting agent is contained in a proportion of 0.01 to 20% by weight of the article.